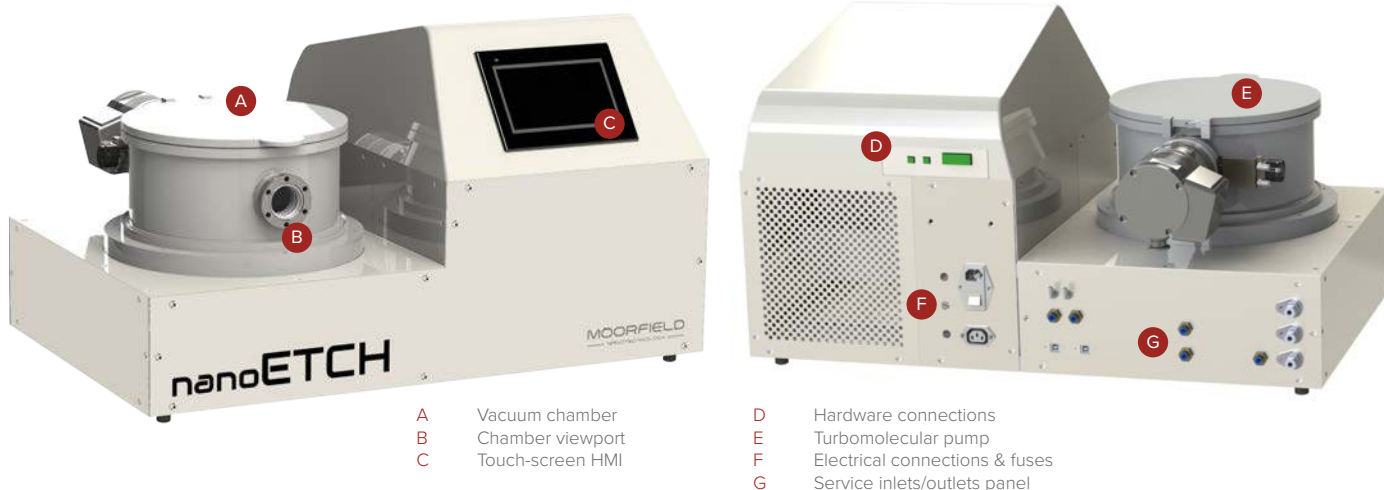


nanoETCH by Moorfield.

Soft-etching system for 2D materials.



MOORFIELD
— NANOTECHNOLOGY —



A Vacuum chamber
 B Chamber viewport
 C Touch-screen HMI

D Hardware connections
 E Turbomolecular pump
 F Electrical connections & fuses
 G Service inlets/outlets panel

Developed with the Nobel Prize winning graphene group at Manchester University, UK, nanoETCH systems provide the fine control needed for substrate and device preparation in world-leading 2D materials research.

Released by Moorfield following extensive collaboration with academic partners, the nanoETCH series has been designed for etching applications needed as part of R&D work based on 2D materials including graphene and transition metal dichalcogenides (TMDs). The instruments, which are fully automatic and touchscreen-operated, are equipped with precisely controlled RF power generation and process gas introduction and are ultra-compact for benchtop location.

- 2D materials “soft-etching”
- Substrate/support conditioning for mechanical exfoliation
- Precision RF powers < 30 W
- Up to 3 MFC-controlled process gases
- Fully automatic operation via touchscreen HMI
- Up to 6” diameter stages
- Base pressures < 5×10^{-7} mbar
- Define/save multiple process recipes
- Automatic pressure control option
- Equipped for easy servicing
- Comprehensive safety features
- Cleanroom compatible
- Proven performance



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